

Topological materials open a new pathway for exploring spin hall materials

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A schematic image of conversion phenomenon from charge current to spin current based on spin Hall effect in $Co_3Sn_2S_2$ layer. Credit: Takeshi Seki et al

A group of researchers have made a significant breakthrough which could revolutionize next-generation electronics by enabling nonvolatility, large-scale integration, low power consumption, high speed, and high reliability in spintronic devices.



Details of their findings were published in the journal *Physical Review B* on August 25, 2023.

Spintronic devices, represented by magnetic random access memory (MRAM), utilize the magnetization direction of ferromagnetic materials for information storage and rely on spin current, a flow of spin <u>angular</u> <u>momentum</u>, for reading and writing data.

Conventional semiconductor electronics have faced limitations in achieving these qualities.

However, the emergence of three-terminal <u>spintronic devices</u>, which employ separate current paths for writing and reading information, presents a solution with reduced writing errors and increased writing speed. Nevertheless, the challenge of reducing energy consumption during information writing, specifically magnetization switching, remains a critical concern.

A promising method for mitigating <u>energy consumption</u> during information writing is the utilization of the spin Hall effect, where spin angular momentum (<u>spin current</u>) flows transversely to the electric current. The challenge lies in identifying materials that exhibit a significant spin Hall effect, a task that has been clouded by a lack of clear guidelines.

"We turned our attention to a unique compound known as cobalt-tinsulfur ($Co_3Sn_2S_2$), which exhibits ferromagnetic properties at <u>low</u> temperatures below 177 K (-96°C) and paramagnetic behavior at <u>room</u> temperature," explains Yong-Chang Lau and Takeshi Seki, both from the Institute for Materials Research (IMR), Tohoku University and coauthors of the study. "Notably, $Co_3Sn_2S_2$ is classified as a topological material and exhibits a remarkable anomalous Hall effect when it transitions to a ferromagnetic state due to its distinctive electronic



structure."

Lau, Seki and colleagues employed theoretical calculations to explore the electronic states of both ferromagnetic and paramagnetic $Co_3Sn_2S_2$, revealing that electron-doping enhances the spin Hall effect. To validate this theoretical prediction, thin films of $Co_3Sn_2S_2$ partially substituted with nickel (Ni) and indium (In) were synthesized. These experiments demonstrated that $Co_3Sn_2S_2$ exhibited the most significant anomalous Hall effect, while (Co2Ni)Sn2S2 displayed the most substantial spin Hall effect, aligning closely with the theoretical predictions.

"We uncovered the intricate correlation between the Hall effects, providing a clear path to discovering new spin Hall materials by leveraging existing literature as a guide," adds Seki. "This will hopefully accelerate the development of ultralow-power-consumption spintronic devices, marking a pivotal step toward the future of electronics."

More information: Yong-Chang Lau et al, Intercorrelated anomalous Hall and spin Hall effect in kagome-lattice Co3Sn2S2 -based shandite films, *Physical Review B* (2023). DOI: 10.1103/PhysRevB.108.064429

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